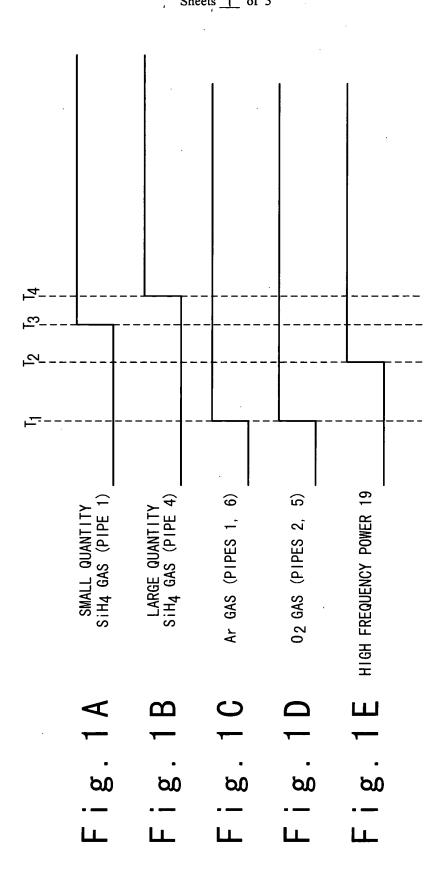
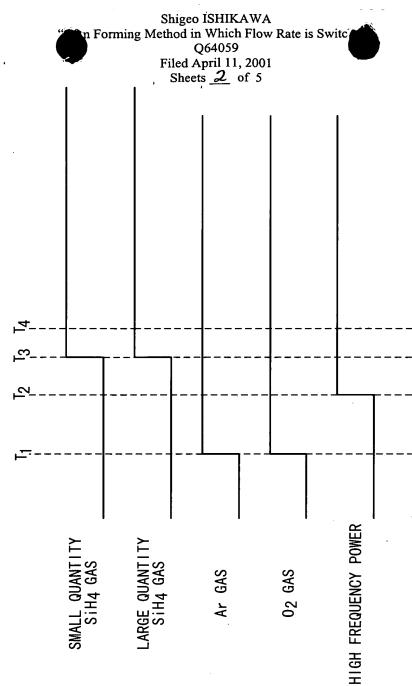
Shigeo ISHIKAWA Forming Method in Which Flow Rate is Switch Q64059 Filed April 11, 2001 Sheets ____ of 5



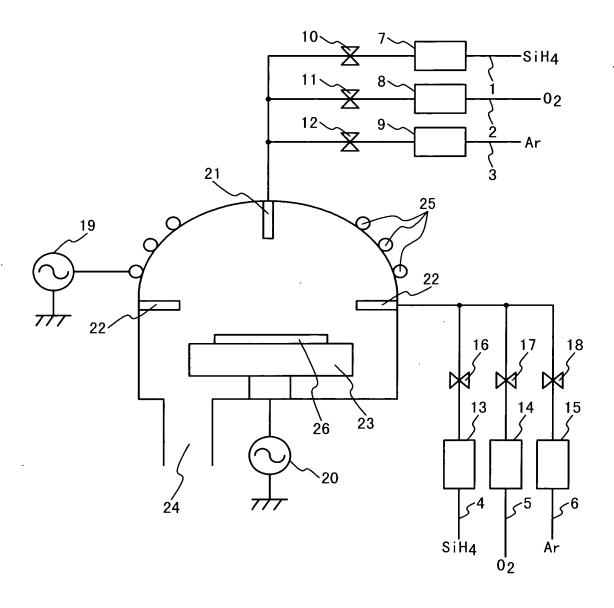


SMALL QUANTITY SiH4 GAS

Shigeo ISHIKAWA

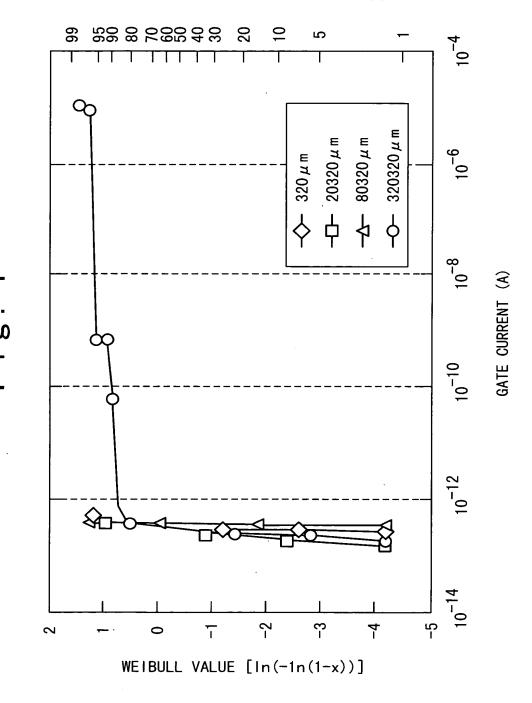
n Forming Method in Which Flow Rate is Switch
Q64059
Filed April 11, 2001
Sheets 3 of 5

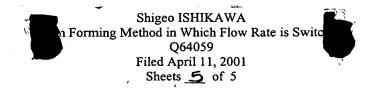
Fig. 3



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ACCUMULATED FAILURE PERCENTAGE (%)





ACCUMULATED FAILURE PERCENTAGE (%)

